

# Manganese iridium

<b>Product</b>	Manganese iridium (sputtering target)
<b>Manufacturer</b>	ACI Alloys Inc.
<b>Composition</b>	80% manganese, 20% iridium; solid
<b>Synonyms</b>	MnIr
<b>Typical Uses</b>	Thin-film material deposited via sputtering.
<b>Hazards</b>	000 Not a hazardous substance or mixture.
<b>Storage</b>	Sputtering target cabinet next to <i>Sputtering System #4 (Moe)</i> .
<b>Disposal</b>	Regular garbage bins in 10k area or cleanroom.
<b>Comments</b>	Approved for sputtering in <i>Sputtering System #4 (Moe)</i> .
<b>Status</b>	



## Check First

Please contact a nanoFAB staff member for uses not listed above.